

*“Ab initio modeling of few-layer dilute magnetic semiconductors”*. Tiwari S, Van de Put ML, Sorée B, Vandenberghe WG, International Conference on Simulation of Semiconductor Processes and Devices : [proceedings]

T2 - International Conference on Simulation of Semiconductor Processes and, Devices (SISPAD), SEP 27-29, 2021, Dallas, TX , 141 (2021).

<http://doi.org/10.1109/SISPAD54002.2021.9592535>